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**CONFIRMATION NO. 4946** 

| Bib Data Sheet   |                                   |               |              |                   |             |   |  |
|--|-----------------------------------|---------------|--------------|-------------------|-------------|---|--|
| SERIAL NUMBER<br>10/660,151  | FILING DATE<br>09/11/2003<br>RULE | C             | CLASS<br>438 | GROUP ART<br>2812 |             | ATTORNEY<br>DOCKET NO.<br>004994<br>RT/ETCH/SILICON |  |
| APPLICANTS   |                                   |               |              |                   |             |   |  |
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| ** CONTINUING DATA **********************************  |                                   |               |              |                   |             |   |  |
| ** FOREIGN APPLICATIONS ************************************   |                                   |               |              |                   |             |   |  |
| none, Of   |                                   |               |              |                   |             |   |  |
| IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** 12/05/2003  |                                   |               |              |                   |             |   |  |
| Foreign Priority claimed  35 USC 119 (a-d) conditions met  Verified and Acknowledged  Acknowledged |                                   | STATE OR      | SHEETS       | TOTAL             | INDEPENDENT |   |  |
|  | itials                            | COUNTRY<br>CA | DRAWING<br>7 | CLAIMS<br>20      |             |   |  |
| ADDRESS  |                                   |               |              |                   |             |   |  |

44182

MOSER, PATTERSON & SHERIDAN, LLP

APPLIED MATERIALS INC

595 SHREWSBURY AVE

SUITE 100

SHREWSBURY, NJ

07702

TITLE .

Process for etching polysilicon gates with good mask selectivity, critical dimension control, and cleanliness

| ·               | ·   | ☐ All Fees                            |
|-----------------|---|---------------------------------------|
|                 |   | 1.16 Fees ( Filing )                  |
| FILING FEE      | FEES: Authority has been given in Paper No to charge/credit DEPOSIT ACCOUNT | 1.17 Fees ( Processing Ext. of time ) |
| RECEIVED<br>750 | No for following:   | 1.18 Fees (Issue)                     |
|                 |   | Other                                 |
|                 |   | ☐ Credit                              |